scientific reports

OPEN



Improving the photoelectrochemical water splitting performance of CuO photocathodes using a protective CuBi₂O₄ layer

Nguyen Hoang Lam¹, Nguyen Tam Nguyen Truong^{1 \boxtimes}, Nam Le¹, Kwang-Soon Ahn¹, Younjung Jo², Chang-Duk Kim^{2 \boxtimes} & Jae Hak Jung^{1 \boxtimes}

A heterojunction photocathode of CuO and CuBi₂O₄ grown on an FTO substrate (FTO/CuO/CuBi₂O₄) was synthesized using hydrothermal method followed by spin coating and annealing to overcome the bottlenecks encountered by CuO in photoelectrochemical (PEC) water splitting application. The synthesis methods, morphological, structural properties, and composition of each sample under each synthesis condition are discussed in detail. The photocathode with 15 coating layers annealed at 450 °C exhibited the best PEC performance. Moreover, its current density reached 1.23 mA/cm² under an applied voltage of – 0.6 V versus Ag/AgCl in a neutral electrolyte. Additionally, it exhibited higher stability than the bare CuO thin film. The bonding of CuBi₂O₄ on CuO resulted in close contact between the two semiconductors, helping the semiconductors support each other to increase the PEC efficiency of the photocathode. CuO acted as the electron-generating layer, and the CuBi₂O₄ layer helped minimize photocorrosion as well as transport the carriers to the electrode/electrolyte interface to accomplish the hydrogen evolution reaction.

PEC water splitting which was first introduced by Fujishima and Honda¹ is a potential technique for hydrogen production for renewable energy applications to help gradually replace fossil fuels and thereby reduce greenhouse gas emissions. Generally, a PEC system converts incident photons from sunlight into electrical energy using specialized materials (semiconductors) immersed in an electrolyte containing redox pairs. Specifically, when the energy of incident photons is equal to or greater than the bandgap energy of a semiconductor, electron–hole (e^--h^+) pairs are generated. Subsequently, electrons move to the photocathode/electrolyte interface to reduce H⁺ into hydrogen gas. Simultaneously, holes transferred to the surface of the photoanode to oxidize water molecules into oxygen gas. The overall reactions related to the water splitting mechanism are presented in Eq. $(1)^2$. Furthermore, the overall reaction in PEC systems is divided into two half-cell reactions: hydrogen evolution reaction (OER, oxidation at the anode to produce oxygen gas (Eq. 3))².

$$2H_2O + h\vartheta \rightarrow 2H_2 + O_2 \quad \Delta G^0 = 4.92 \text{ eV} (113 \text{ kcal mol}^{-1})$$
(1)

$$2H^+ + 4e^- \rightarrow 2H_2 E^o_{red} = 0 V$$
 (2)

$$2H_2O \rightarrow 4H^+ + 4e^- + O_2 E^o_{red} = 1.23 V$$
 (3)

In PEC cells, semiconductors play an important role in oxidation and reduction. Semiconductors can capture light and provide energy for chemical reactions. Additional voltage is required to supply sufficient voltage to PEC cells to drive reactions at the expected current densities³. Currently, numerous semiconductors have been

¹School of Chemical Engineering, Yeungnam University, 280 Daehak-ro, Gyeongsan 38541, Republic of Korea. ²Department of Physics, Kyungpook National University, Daegu 41566, Republic of Korea. [⊠]email: tamnguyentn@ynu.ac.kr; duks@knu.ac.kr; jhjung@ynu.ac.kr

used in PEC water splitting system such as BiVO₄⁴⁻⁶, Fe₂O₃⁷, TiO₂⁸, Si⁹, Cu₂O¹⁰, CaFe₂O₄¹¹, CuRhO₂¹², etc. Each material has its own properties for application to a photoanode or photocathode. Among these semiconductors, CuO has several advantages to being a photocathode, such as a narrow bandgap (1.2-2.0 eV), nontoxicity, abundant on Earth, capability to absorb light in the visible-light¹³, and a high theoretical photocurrent density (35 mA/cm²)¹⁴. However, CuO has the following drawbacks that scientists need to modify and improve: (1) The tendency of CuO to accumulate generated electrons on the electrode surface can cause self-reduction of CuO into Cu₂O or Cu; (2) Giving their tendency for self-reduction, CuO photocathodes have low stability, which results in shortened electrode lifetimes¹⁵. The problems associated with CuO involve the improvement of photostability and the enhancement of lifetime. The latter is crucial for fabricating photocathodes for PEC water splitting. CuBi₂O₄ is a p-type metal oxide with lower theoretical photocurrent density than CuO (only 19 mA/cm^{2})¹⁶. Although bare CuBi₂O₄ has a considerably low current density of 0.3–0.5 mA/cm^{217,18}, it has several advantages: (1) it has a narrow bandgap (1.5-1.8 eV) that helps to absorb light in the visible range¹⁹; (2) it is formed from Earth-abundant elements (Cu, Bi, and O) and is therefore a low-cost material with low toxicity²⁰; (3) its conduction band position is suitable for the reducing small molecules, such as CO_2 , H_2O , and $O_2^{16,21,22}$; and (4) most importantly, it is more stable than other binary copper compounds (Cu₂O or CuO) and can thus act as a protective layer in photocathodes to resist photo-corrosion²². Several methods have been proposed to assist the separation and transport of e^--h^+ pairs in semiconductors. They include heterojunction formation, structural defect generation, and doping²³. In particular, the heterojunction structure fulfills the requirements for ideal PEC photocathodes, such as high redox capacity, efficient charge separation, and wide light absorption range²³. Until now, heterojunctions of CuO and CuBi₂O₄ have been widely studied. For example, Pulipaka et al.²⁴ synthesized CuO/CuBi₂O₄ films via annealing at high temperatures between two cycles of electrodeposition. The obtained films generated a high current density $(-0.9 \text{ mA/ cm}^2 \text{ at } 0.1 \text{ V vs. RHE})$. The H₂O₂ yield of a Gd³⁺ doped CuBi₂O₄/CuO heterojunction film considerably increased and was six times higher than that of an un-doped $film^{25}$. Additionally, Zhang et al.²⁶ constructed a CuO/CuBi₂O₄ bilayer decorated with a NiO_x electrocatalyst via pulse chronoamperometric deposition followed by the hydrothermal method. This photocathode exhibited a photocurrent density of 2.17 mA/ cm² at 0.2 V versus RHE in a neutral electrolyte, and retained 82.5% of its photostability during 300 min of continuous illumination. In this study, we used a simple method (hydrothermal method followed by spin coating and annealing) to fabricate FTO/CuO/CuBi₂O₄ heterojunctions. We found that changes in thickness and crystallinity according to coating layer number and annealing temperature resulted in structural changes that improved the PEC properties of semiconductors.

Results-discussion

Fig. S2 in the Supplementary Information (SI) shows the X-ray Difraction (XRD) peaks of CuO, the sample with five coating layers (5CL), and the sample with five coating layers annealed at 450 °C (5CL450) grown on the surface of the FTO substrate. The spectrum of the 5CL450 sample exhibited strong peaks at approximately 20.8°, 27.9°, 29.3°, 30.6°, 46.1°, and 55.1° corresponding to the planes (2 0 0), (2 1 1), (2 2 0), (0 0 2), (4 1 1), and (3 3 2), respectively (ICDD No. 00-42-0334) indicating that $\overline{\text{CuBi}_2\text{O}_4}$ layer was successfully synthesized^{17,27}. Moreover, the peaks of CuO were also found in the XRD spectrum at 35.64 °, 38.90 °, and 53.62 ° corresponding to the planes (-111), (111), (202), respectively (ICDD No. 00-041-0254)²⁸. Comparing the XRD peaks of 5CL with 5CL450 revealed that the XRD diffraction peaks of CuBi₂O₄ appeared only after annealing. This finding demonstrated that heat treatment is an important step in crystallizing the coating into CuBi₂O₄. The XRD spectra of FTO/CuO/CuBi₂O₄ synthesized at different temperatures (350 °C, 450 °C, and 550 °C) with different numbers of coating layers (5, 10, and 15) were acquired (Fig. 1) to evaluate the relation among crystal structure, thickness, and annealing temperature. The intensities of XRD peaks changed at different temperatures. The intensities of the XRD peaks of CuBi₂O₄ increased with increasing temperature. Coating thickness also affected the intensity of the XRD peaks. In particular, the intensity of the planes of (2 0 0) at 20.8 ° and (2 1 1) at 27.9 ° decreased as the number of coating layers increased from 5 to 15 under heating at 350 °C because the thicker the coating, the less complete the crystallization. Therefore, the annealing temperature of 350 °C was considered to be considerably low for complete crystallization of the coatings into CuBi₂O₄. No considerable differences were found between the XRD spectra of the cathode annealed at 450 °C and that annealed at 550 °C regardless of the number of coating layers. Using the Scherrer's equation (Eq. 5) to calculate the estimated crystalline size of all samples revealed that crystallite size increased with increasing temperature (Table 1). This result was in line with the results of previous studies^{24,28,29}. Furthermore, the crystallization parameters revealed the structure of the FTO/CuO/CuBi₂O₄ film. Dislocations (Eq. 6) are anomalies in crystal structures. Similar to micro-strain (Eq. 7), dislocation in the sample tended to decrease at high temperatures. These two parameters changed inversely with crystal size, because the appearance of grain boundaries decreased owing to the increase in crystal size with increasing temperature^{28,30}.

Grain size and layer thickness play crucial roles in terms of the efficiency of PEC water splitting. Scanning Electron Microscopy (SEM) was performed to confirm the morphology of samples and calculate thin film thickness. Fig. 2 shows the morphology and thickness of all samples, including the FTO substrate coated with the CuO layer after the hydrothermal process. The top surfaces of the samples were covered by a CuBi₂O₄ layer. However, the nominal thickness of each sample differed under treatment at various temperatures with the same number of coating layers. The thickness of the sample with five coating layers on CuO was $1.39 \,\mu\text{m}$ (S05000). Layer thickness substantially decreased after treatment at high temperature. Specifically, the thicknesses of S05350, S05450 and S05550 were 794, 675 and 476 nm, respectively. The cross-section of S05000 showed that the two layers of CuO and CuBi₂O₄ had bonded together, and a continuum was found at the grain boundary of the two types of materials that will help improve the charge transfer efficiency and enable the uninterrupted transfer of generated photoelectrons to the electrode/electrolyte interface²⁴. The top planar SEM image of the samples illustrated that the structure of the CuBi₂O₄ layer was unstable in the sample annealed at 550 °C; that voids were present



Figure 1. X-ray Difraction (XRD) spectra of FTO/CuO/CuBi₂O₄ fabricated with different numbers of coating layer at different annealing temperatures. Triangular dots represent the peaks of CuBi₂O₄ crystals based on JCPDS No.42.0334, and square dots represent the peaks of CuO crystals based on ICDD No#00-041-0254.

.....

		Annealing temp	Crystallite size	Micro-stain	Dislocation density	Thickness	Band gap		Atomic percent		age (%)
Sample	Coating layers	(°C)	[A]	(%)	(δ)	(nm)	(eV)	Flat band (V)	0	Cu	Bi
S05000	5	-	-	-	-	1390	-	-	53.38	37.23	9.39
S05350	5	350	199.07	0.108	3.04E-05	794	2.71	1.50	57.37	27.45	15.18
S05450	5	450	209.24	0.108	3.31E-05	675	2.66	0.40	57.06	28.15	14.79
S05550	5	550	211.52	0.099	2.47E-05	476	2.45	0.66	59.60	27.75	12.65
S10350	10	350	188.82	0.113	3.32E-05	754	1.85	0.50	54.84	30.91	14.26
S10450	10	450	200.81	0.109	3.21E-05	675	1.78	0.23	56.95	28.77	14.28
S10550	10	550	257.52	0.082	1.70E-05	675	1.70	0.66	60.43	26.76	12.81
S15350	15	350	213.57	0.102	2.79E-05	337	2.53	0.65	63.92	18.51	17.57
S15450	15	450	232.41	0.092	2.19E-05	655	1.51	0.67	60.23	22.93	16.84
S15550	15	550	250.41	0.084	1.80E-05	575	1.55	0.68	61.70	24.39	13.91

Table 1. Crystallographical parameters of samples.

in the top layer, revealing the surface of the CuO layer below, in S05550, and S10550; and that some vertical, non-uniform structures appeared on the surface of \$15550. \$15450 was thicker than \$15550 because the thickness of S15550 was determined only to the edge of the upper CuBi_2O_4 layer and vertically grown crystals were excluded. In some samples annealed at lower temperatures (\$05350, \$10350, and \$15350), the coatings were not completely converted into CuBi₂O₄, and discrete fractions or even discrete particles were produced. This finding was consistent with the XRD results discussed earlier. In these cases, the protective function of the $CuBi_2O_4$ layer was attenuated. The optimal annealing temperature for the formation of a flat, bonded, and homogenous surface was 450 °C, which enabled the coating layers to transform and bond with each other. SI-Fig. S3ab depicts the structure of S15450 in cross-section and planar-view, respectively. The thicknesses of the CuO and CuBi₂ O_4 layers were 357 and 278 nm, respectively. These images also illustrate the bonding of the particles on the surface and clearly indicate the order of the layers of the material (CuO layer below and $CuBi_2O_4$ layer above). SEM – Energydispersive X-ray spectroscopy (EDS) was performed to confirm the chemical compositions of the samples. Bi, Cu, and O atoms were present on the surfaces of the samples (see SI-Fig. S4). The results showed that the top layer of the samples had high Cu, Bi, and O contents. Furthermore, in some samples with some voids in the top layer, the disappearance of Bi from the lost parts demonstrated that the bottom layer contained only Cu and O, indicating the presence of a layer of CuO. A precursor solution was prepared with Cu:Bi ratio of 4:1. \$05000 presented correct proportion (Table 1). The formation of the heterojunction structure of CuO/CuBi₂O₄ on the surface of FTO substrate was confirmed on the basis of SEM images and XRD results. The heterojunction can be defined and modeled using VESTA software (version 3)³¹ (SI-Fig. S5).





The aforementioned analyses indicated that S15450 may possess the necessary structure for improving the efficiency of PEC water splitting. The XPS technique was used to evaluate the chemical states of the elements on the surface of S15450. Fig. 3 shows the XPS spectrum of S15450. The survey spectrum shows that only three elements, i.e., Cu, Bi, and O (Fig. 3a) existed in the sample. The three high-resolution spectra of S15450 in Fig. 3b–d show the peaks of O, Bi, and Cu. The peak of element O1s at 529.65 eV was attributed to lattice O, while the small shoulder peak at 531.25 eV was ascribed to O absorption or defects²⁹; Two Bi peaks originating from Bi4f_{3/2} and Bi4f_{1/2} were found at 158.57 and 163.88 eV, respectively, confirmed the presence of Bi³⁺ in CuBi₂O₄²⁹. The XPS spectrum of Cu shows two main peaks at 933.51 and 953.69 eV that originated from Cu2p_{3/2} and Cu2p_{1/2}, respectively. Moreover, the Cu2p peak positions and the appearance of two satellite peaks reveal the existence of Cu²⁺ in CuBi₂O₄³². Additionally, the XPS spectra (survey and high-resolution spectra) of all samples were acquired to investigate the effect of coating number and annealing temperature. The spectra are shown in SI–Fig. S6 and S7. Overall, all samples exhibited similar peaks in their spectra. The negligible changes in the XPS peaks of the elements with the variation in annealing temperature and thickness indicated the absence of change in the chemical environment of elements in the lattice²⁹.

The ability of a material to absorb light is the most important factor in the water splitting via PEC. The material must efficiently absorb photons from the light source and generate $e^- - h^+$ pairs to produce photo current density¹⁷. UV-visible spectrophotometry was performed to obtain an insight into the possibility of light harvesting by the FTO/CuO/CuBi₂O₄ photocathodes. The absorbance spectra of FTO/CuO/CuBi₂O₄ photocathodes are shown in SI–Fig. S8. The optical properties of any material are heavily dependent on the crystal microstructure³³. All photocathodes exhibited strong absorption at around 300–400 nm, which subsequently reduced the incident photon with low energy (> 600 nm). S15450 and S10550 exhibited the highest absorption at 337 nm, indicating that FTO/CuO/CuBi₂O₄ photocathodes can only absorb the photons under high-energy illumination (violet part). These findings, in combination with morphological properties (Fig. 2), clearly illustrated the influence of morphology on optical properties. Samples with rough surfaces and irregular structures produce considerable light scattering, thereby reducing the perceived absorbance³⁴. In particular, S05550, and S10550 had some voids in their surfaces, and S15550 contained some vertical structures that increased light scattering and reduced light absorption.

The Tauc plot of the photocathodes was obtained using Eq. (4) and the estimated bandgap was defined as follows:



Figure 3. (a) X-ray photoelectron spectroscopy (XPS) survey spectrum of sample S15450 with the high-resolution XPS spectra of (b) O1s, (c) Bi4f, and (d) Cu2p.

$$\alpha h \nu = \mathcal{A} \left(h \nu - \mathcal{E}_{g} \right)^{1/n} \tag{4}$$

where n takes the value of $\frac{1}{2}$ for the direct (allowed) bandgap Tauc plot; A denotes the absorption constant; and α , E_g , and ν denote the absorption coefficient, bandgap, and light frequency, respectively³³. The bandgaps of FTO/CuO/CuBi₂O₄ are presented in Table 1; these bandgaps were a slightly wider than those of the CuO thin film (2.12 eV)²⁸. SI–Fig. S9 showed the bandgaps based on the absorption of FTO/CuO/CuBi₂O₄ under different experimental treatments with approximately similar light adsorption ranges calculated on the basis of $(\alpha h\nu)^2$ versus hv. A small change in bandgap energy can also cause a slight improvement in material absorptive capacity. Specifically, the sample with narrow bandgap of 1.51, 1.55, 1.65 and 1.74 eV includes S15450, S15550, S10550 and S10450, respectively. Wide bandgaps were found in samples in five coating layers samples (including samples S05350, S05450 and S05550 with bandgap of ~2.71, 2.66, and 2.45 eV respectively). The bandgaps of these photocathodes widened owing to the incomplete conversion of the coating to CuBi₂O₄ at 350 °C, as discussed earlier. In addition, compared in the same coating layer, higher temperature led to decrease bandgap. Because the crystal lattice tends to expands and the inter atomic bond is weaker at higher temperature. However, bandgap of sample S15550 is a little bit higher than S15450, it is probably due to the appearance of vertical structures on the surface. Previous studies^{24,25,34} have shown that CuBi₂O₄ and CuO can form the staggered band alignments owing to theirs type II heterojunction.

Mott-Schottky analysis was performed at 1 kHz in a 0.1 M Na₂SO₄ aqueous solution to estimate the flat-band of the FTO/CuO/CuBi₂O₄ photocathodes. The results are presented in Table 1. The change in the flat-band potential of the materials under different experimental treatments (see Fig. 4a–c) indicated that the regression line of the FTO/CuO/CuBi₂O₄ photocathodes had a negative slope, indicating that the photocathodes were p-type semiconductors. Semiconductor S15450 exhibited a flat-band value of 0.67 V versus Ag/AgCl (1.2 V vs. RHE). The flat-band potential of a p-type semiconductor is roughly equal to that of its valence band^{35,36}. As inferred from this result and SI–Fig. S9, the conduction band of the sample is located at – 0.31 V versus RHE. The band position of the electrode (proposed demonstration sample S15450) is shown in Fig. 4d. The bandgap precisely straddles in the redox potential of water demonstrating the potential of the FTO/CuO/CuBi₂O₄ photocathode to generate hydrogen via water splitting³⁶.

PEC experiments were conducted in a three-electrode configuration. FTO/CuO/CuBi₂O₄ with various numbers of coating layers and heat treatment was used as the photocathode. The current densities are measured at -0.6 V versus Ag/AgCl at a scan rate of 10 mV/s. The chopped (dark/light) linear scanning voltammetry (LSV) scans of the CuO, 5CL450, and 5CL layers are presented in SI–Fig. S10. As can be seen, the CuO layer exhibited a potential of 0.49 mA/cm² under the applied voltage of -0.6 V versus Ag/AgCl, whereas the 5CL450 layer exhibited a slightly higher potential (0.36 mA/cm²) under the same applied potential. The coating layers that were not subjected to annealing did not react to light and their potential reached 0.27mA/cm². Another experiment was conducted to compare the PEC performances of the CuO and CuBi₂O₄ layers combined into a heterojunction. The results demonstrated at the current density increased sharply (Fig. 5a). In the heterostructure, the CuO layer of the photocathode served as an electron donor in the PEC process and the CuBi₂O₄ film acted as a protective







Figure 5. (a) Comparison of current density (chopped linear scanning voltammetry (LSV)) in a 0.1 M Na₂SO₄ electrolyte solution at pH 6.89 under illumination using Xe lamp (AM1.5G 100 mW/cm²); (b) Applied bias photo-to-current efficiencies (ABPEs) of FTO/CuO/CuBi₂O₄ photocathodes obtained from three-electrode configuration calculated and plotted from LSV data (Eq. 8).

layer against the photocorrosion of the underlying CuO layer and as the transport layer that transferred electrons to the electrode/electrolyte interface²⁴. Among all photocathodes in all coating and temperature cases FTO/CuO/CuBi₂O₄ at annealed 450 °C exhibited the highest current density. Specifically, the current densities of S10450 and S15450 were 1.07 and 1.23 mA/cm² at $-0.6 V_{Ag/AgCl}$, respectively. The lowest efficiency was exhibited by S05350, S10350, and S15350; the corresponding current densities were 0.38, 0.72, and 0.53 mA/cm² at $-0.6 V_{Ag/AgCl}$, respectively. These results were consistent with the analysis of bandgap structure presented earlier. The enhanced current density of FTO/CuO/CuBi₂O₄ annealed at 450 °C had two possible reasons: First, the improvement in crystal size led to improve charge transport in layers with reduced grain boundaries. Second, CuBi₂O₄ completely crystallized at 450 °C, the coating was not completely converted at 350 °C, and CuBi₂O₄ had an unstable structure, and formed voids on its surface when annealed at 550 °C (discussed in the SEM section).

The applied bias photo-to-current efficiencies (ABPEs) of the samples are presented in Fig. 5b. APBE is used to quantitatively evaluate the hydrogen PEC generation efficiency of photocathodes^{34,37} and was calculated on the basic of the applied bias between the counter and working electrode and LSV measurements (Eq. 8). Comparing the three annealing temperature levels revealed that the photocathodes fabricated at 450 °C exhibited a marked enhancement in efficiency compared with the samples annealed at 350 °C. Additionally, annealing at 550 °C caused a reduction in ABPE owing to the formation of a heterogeneous structure (see SI–Fig. S3dgj)³⁷. In the group of photocathodes annealed at 450 °C, the sample with 15 coating layers achieved the highest efficiency (0.74%) compared with the samples with 10 and 5 coating layers (0.69% and 0.59%, respectively). These results demonstrated that the photocathode was effective in splitting e^-h^+ pairs and can inhibit charge carrier recombination, thereby improving the overall efficiency of PEC water splitting³⁸.

Incident photon-to-current conversion efficiency (IPCE) was used to measure the ratio of photocurrent versus incident photons as a function of wavelength to elucidate the mechanism of the $FTO/CuO/CuBi_2O_4$ photocathode³⁴ (Fig. 6a). As expected, ICPE tended to be similar to the measured current density. IPCE peaked at approximately 310-340 nm and increased with the increasing number of coating layers; the highest conversion efficiency was exhibited by \$15450 (93.14%). All samples exhibited low external quantum efficiencies at long-wavelength (> 600 nm) because they had low quantum yield in the conversion of with energies close to the bandgap¹⁶. The IPCE data were used to calculate the absorbed photo-to-current density (APCE) by Eq. (10). FTO/CuO/CuBi₂O₄ can convert most of the photons close to the absorption edge as proven by measuring the bandgap and absorption of the photocathodes. The APCE curves of all photocathodes were similar in shape, and APCE values were not significantly higher than IPCE values (Fig. 6b). Peaks were located at approximately 310-340 nm (with 93.16%), and the internal quantum efficiencies decreased to zero at long wavelengths (>600 nm). The differing APCE values of the photocathodes and the lower APCE indicate of differing absorption or the poor transport of carriers³⁹. The IPCE and APCE of S15450 were 11.98 and 8.91 times higher than the external and internal quantum efficiencies of the CuO layer, respectively (SI-Fig. S11). These findings illustrate that the CuBi₂O₄ layer exhibited good efficiency in absorbing photons and transferring charge carriers to generate photocurrents. As illustrated in Fig. 6, and SI-Fig. S11, all the photocathodes exhibited good transition in the



Figure 6. (a) Incident photon-to-current conversion efficiency (IPCE) plot of FTO/CuO/CuBi₂O₄ fabricated with different number of coating layers and at different annealing temperatures. IPCE was measured at a potential of -0.6 V in a 0.1 M Na₂SO₄ and calculated using the Eq. (9); and (b) Absorbed photo-to-current density (APCE) plot obtained from IPCE data and absorbance values (Eq. 10).

violet part of illumination (300–400 nm), indicating that only incident light with high energy may be absorbed and converted to currents.

A chronoamperometry test was conducted on FTO/CuO and FTO/CuO/CuBi₂O₄ (S15450) in a 0.1 M Na₂SO₄ electrolyte (pH 6.8) at a fixed potential (-0.6 V vs. Ag/AgCl) under continuous illumination for 7200 sec to test the PEC stability of the photocathodes; the results are presented in Fig. 7a. The J-t plot shows that the current density of the photocathode coated with CuBi₂O₄ increased. Consistent with the data in Fig. 5, the photocurrent of the photocathode with $CuBi_2O_4$ layer shows two times higher than that of the photocathode without $CuBi_2O_4$. The photocurrent density of both photocathodes decreased rapidly at first ~300 s and then gradually stabilized during the stability test, indicating that the semiconductor-electrolyte interface was affected initially⁴⁰; after a period of adaptation with medium, the photocathode gradually stabilizes. Morphology change of photocathode S15450 is given in Fig. 7c, d. Apparently after applying external voltage (-0.6 V vs. Ag/AgCl) and reacting in the electrolyte for 7200 s, the surface of electrode have changed a little bit. Specifically, CuBi₂O₄ layer was corroded at some points. The cross-section exhibited the present of $CuO/CuBi_2O_4$ layer on the top, but thinner. After the stability test in neutral electrolyte, the XPS spectrum (Fig. 7b) exhibited the profile of the O1s, Cu2p, and Bi4f peaks is still similar to those of sample before test. Normally, the reaction on the photocathode's surface is the reduction, which will attract positive ions (H^+) to the interface and reduce to H₂ gas, or the material of photocathode will be reduced to other substances. Since there is no change, i.e. the peaks have not been shifted, on the XPS spectra between before and after the test, the CuO/CuBi₂O₄ photocathode has not been converted to another substance but is slightly corroded on the surface. Compared to the result of stability test, surface corrosion can occur in the first ~300 s, so it led to a significantly reduced current density. After that, it would have been possible that less (or no further) corrosion would occur, due to the steady generated current density during the rest of the stability test. The FTO/CuO photocathode showed a relatively low PEC efficiency that improved when it was coated with $CuBi_2O_4$ without the loading of other precious metals. Therefore, $CuBi_2O_4$ has potential to increase the efficiency of photocathodes. To further elucidate the role of CuBi₂O₄ layer in increasing the efficiency of current density of CuO/CuBi₂O₄ photocathode, PL spectra were investigated. Fig. S12 exhibited the PL intensity of CuBi₂O₄ layer was quite low, and this spectrum matched with the report of Wang et al.⁴¹. The similar PL peaks of CuO and CuO/CuBi₂O₄ show that the CuBi₂O₄ thin layer does not compete with CuO⁴². In addition, the PL emission intensity of the CuO layer decreased sharply after the inclusion of CuBi₂O₄, demonstrating that the carriers are separated more efficiently due to the presence of type II heterojunctions with suitable high-energy band sites²⁵. The PL emission peaks from the $CuO/CuBi_2O_4$ photocathode become relatively weak, indicating a decrease in electron-hole recombination⁴¹. As can be clearly determined from these results, $CuBi_2O_4$ acts as a protective layer to prevent self-reduction of the CuO layer, increase photon absorption, as well as limit recombination of e⁻-h⁺ pair by transporting electrons accumulated on the edge of the CuO layer to the electrode/electrolyte interface and perform the reduction reaction of H^+ to H_2 . Table 2 presents the comparison of the stabilities reported by other studies on $CuBi_2O_4$. In contrast to the photocathodes reported by other studies, the $FTO/CuO/CuBi_2O_4$



Figure 7. (a) Stability test on FTO/CuO and S15450 (FTO/CuO/CuBi₂O₄) photocathodes under 7200 s of illumination (0.1 M Na₂SO₄ electrolyte pH 6.8). The test performed at an applied potential of -0.6 V versus Ag/ AgCl; (b) the XPS survey spectrum of sample S15450 before and after stability test; (c) and (d) are the SEM images (the inset images are the cross-section of each sample) of photocathode S15450 before and after stability test, respectively;

Photocathode	Applied Potential	Electrolyte (pH)	Testing time (s)	Photocurrent density (at stable period) (mA/ cm ²)	Ref.
FTO/CuO/CuBi ₂ O ₄	-0.6 V versus Ag/AgCl	0.1 M Na ₂ SO ₄ (pH 6.7)	7200	0.4	In this study
CuO/CuBi ₂ O ₄ /NiO _x	0.6 V versus RHE	0.1 M NaOH (pH=12.8)	18,000	~ 0.5	26
CuBi ₂ O ₄	0.6 V versus RHE	$\begin{array}{l} 0.3 \mbox{ M } K_2 {\rm SO}_4 \mbox{ and } 0.2 \mbox{ M} \\ \mbox{ phosphate buffer (pH } \\ 6.65) \\ \mbox{ (With } H_2 O_2 \mbox{ as an electron scavenger)} \end{array}$	7200	~ 0.97	17
CuBi ₂ O ₄ /ZnSe/P25	0.3 V versus RHE	0.3 M K_2SO_4 and 0.2 M phosphate buffer (pH=6.65)	5000	0.43	38
Bare CuBi ₂ O ₄	0.6 V versus RHE	$0.3 \text{ M K}_2\text{SO}_4 \text{ and } 0.2 \text{ M}$ phosphate buffer (pH 7)	18,000	~ 0.1	39
CuBi ₂ O ₄	-0.4 V versus Ag/AgCl	0.1 M Na ₂ SO ₄	200	0.45	43
CuBi ₂ O ₄ /Au/N, Cu–C	0.5 V versus RHE	0.3 M K ₂ SO ₄ and 0.2 M Phosphate buffer (pH 6.68)	3000	0.31	44

Table 2. Comparing of the photoelectrochemical stabilities of CuBi₂O₄-related photocathodes.

photocathode developed in this study exhibited good and stable PEC performance in the water splitting process without the addition of rare metals.

Conclusion

A FTO/CuO/CuBi₂O₄ photocathode was synthesized using the hydrothermal method followed by spin coating and annealing. The techniques used in this study confirmed that 15 coating layers annealed at 450 °C formed a homogenous CuBi₂O₄ layer without cracking, or voiding on the surface and with a continuous interaction with the underlying CuO layer. The absence of gaps between the two layers supported charge transportation. The experimental results indicated that the optimal current density of 1.23 mA/cm² was achieved at $-0.6 V_{Ag/AgCl}$ in a neutral electrolyte 0.1 M Na₂SO₄. The stability of the FTO/CuO/CuBi₂O₄ photocathode was better than that of the photocathode without CuBi₂O₄. These results confirmed the potential of the CuBi₂O₄ layer as a protective electrode layer that reduces recombination, improves the efficiency of the underlying CuO layer during PEC water splitting, and increases the current density. The intimate contact between CuO and CuBi₂O₄ layer prevents the contact between the electrolyte and CuO layer, thereby reducing the potential of CuO for self-reduction into Cu₂O or Cu in the PEC water splitting process; (2) The CuBi₂O₄ layer transports the electrons that have accumulated on the edge of the CuO layer to the electrode/electrolyte interface, thereby reducing recombination. This study demonstrated that when properly designed, p-type heterojunction materials can exhibit improved properties for HER.

Methods

Synthesis the CuO thin film. The CuO thin film was synthesized by the hydrothermal method²⁸. First, the FTO substrates were cleaned in three steps using methanol, ethanol, and deionized water (DIW), respectively. The substrates were dried under a robust stream of nitrogen. A mixed precursor solution consisting of $Cu(C_2H_3O_2)_2$ ·H₂O 0.5 M and CH₃COONa 2 M was sonicated at 30 min before adding to a Teflon-lined stainless steel autoclave. The substrates (1.5 × 2 cm) were slanted inside the autoclave, the FTO side facing down. Next, the autoclaves were tightly covered and maintained at 150 °C for 12 h, with a heating rate of 1 h. After incubation, the samples were cleaned twice with DIW and ethanol, respectively. Finally, the CuO-coated substrate was dried on a hot plate at 60 °C for 30 min. All chemicals in this study were purchased commercially from Sigma Aldrich Company without further purification.

Synthesis the CuBi₂O₄ layer. 0.25 M Cu(NO₃)₂·3H₂O was prepared in ethanol and 2 M Bi(NO₃)₃·5H₂O was prepared in lactic acid. Each solution was stirred with a magnetic stirrer until completely dissolved. The precursor solution was prepared by mixing the above solutions (4 parts of Cu²⁺ and 1 part of Bi³⁺ to total volume) and a Cu:Bi atomic ratio of 1:2. The CuBi₂O₄ layer was synthesized by the spin coating method followed by heat treatment. Specifically, the above CuO samples were put on the spin coating machine, set the program at 2000 rpm for 20 s each time, and the precursor solution was dropped on the surface. Samples prepared for 5, 10 and 15 layers were dried for 10 min at 85 °C on a hot plate. Then the samples were incubated in the air for 2 h at 350 °C, 450 °C, and 550 °C. The experimental summary diagram has been shown in Figure S1.

Characterizations. In order to confirm the characteristics of samples, 4 techniques were used. The Scanning Electron Microscope (SEM) technique was performed in Hitachi S-4800 model equipped with EDS was used to define the morphology and element composition of samples. The top view was taken to define the morphology changing of sample under different annealing temperature; the cross-section was taken for layer thickness determining. X-ray electron spectroscopy (XPS, ESCALABTM 250Xi model, Thermo ScientificTM) was

used to determine the valence state as well as the chemical composition of the sample. PL measurements (Model: FluoroLog-iHR320, Horiba Jobin-Yvon) were performed at room temperature using a spectrophotometer with a 150 W Xenon lamp to verify the formation of heterojunction. The crystal and phase structure of samples were determined by XRD technique (using PANalytical X' pert PRO machine with Cu K α radiation, $\lambda = 1.5406$ Å). From the XRD spectra, some structural properties were calculated including crystalline size (D), dislocation density (δ), and micro-strain (ϵ) using the Eqs. (5, 6, 7), respectively²⁸.

$$D = \frac{k\lambda}{\beta \cdot \cos \theta}$$
(5)

$$\delta = \frac{1}{D^2} \tag{6}$$

$$\varepsilon = \frac{\beta}{4 \cdot \tan \theta} \tag{7}$$

where k = 0.94 which is the Scherer constant, $\lambda = 1.54178$ Å which is the wavelength of X-ray, β is the full width at half maximum (FWHM) of the diffraction peak and θ is the Bragg's angle of diffraction peak.

Photoelectrochemical measurements. PEC measurements were performed in a three-electrode configuration consisting of a working electrode (samples), a reference electrode (Ag/AgCl) and a counter electrode (Pt plate). Samples were applied with Loctite 1C Hi-Sole Epoxy/White adhesive for electrode connection as well as limiting the remaining active area to 1 cm^2 . Electrolyte was 0.1 M sodium sulfate buffer (pH = 6.89). A Xe illuminator (AM1.5G 100 mW/cm²) was used to simulate the light source in this experiment. Photo-current density was obtained by applying a linear sweep voltammetry (LSV) with a scan rate of 10 mV/s in the voltage range -0.6 to 0.0 V. Besides, there are some diagnostics in the PEC measurement were used in this study. The Applied Bias Photo-to-current Efficiency (ABPE) was calculated by Eq. (8)³⁴. Eq. (9) and (10) were used to calculate the Incident Photo-to-current Efficiency (IPCE) and Absorb Photo-to-current Efficiency (APCE), respectively³⁴.

$$ABPE = \frac{J_{ph} \times (1.23 - V)}{P_{light}} \times 100 \%$$
(8)

$$IPCE = \frac{|J_{ph}| \times hc}{P_{mono} \times \lambda}$$
(9)

$$APCE = \frac{IPCE}{\eta_{e^-/h^+}}$$
(10)

where J_{ph} (mA/cm²) is the measured photocurrent density, P_{mono} is monochromatic illuminance power density, c is the speed of light, h is a constant of Planck, λ is the wavelength, η_{e^-/h^+} is the absorbance, P_{light} (mW/cm²) is the incident light power density, and V is the potential applied in the cell (vs. Ag/AgCl). The applied potentials in all experiments were converted to the reversible hydrogen electrode (RHE) scale using the Nernst equation (Eq. 11)⁴⁵:

$$E_{RHE} = E_{(Ag/AgCl)} + E_{(Ag/AgCl)}^{0} + 0.059 \times pH$$
(11)

where $E_{(Ag/AgCI)}$ is the potential applied on working electrode, $E^{\circ}_{(Ag/AgCI)} = 0.197$ V at ambient temperature (25 °C).

Data availability

The data supporting the findings of this research are available within the article and supplementary information.

Received: 27 January 2023; Accepted: 3 April 2023 Published online: 08 April 2023

References

- 1. Fujishima, A. & Honda, K. Electrochemical photolysis of water at a semiconductor electrode. Nature 238, 37-38 (1972).
- 2. Joy, J., Mathew, J. & George, S. C. Nanomaterials for photoelectrochemical water splitting-review. Int. J. Hydrog. Energy 43,
- 4804–4817 (2018).
 Gopalakrishnan, S. & Jeganathan, K. Facile fabrication of silicon nanowires as photocathode for visible-light induced photoelectrochemical water splitting. *Int. J. Hydrog. Energy* 42, 22671–22676 (2017).
- Gao, R. T. & Wang, L. Stable cocatalyst-free BiVO₄ photoanodes with passivated surface states for photocorrosion inhibition. Angew. Chem. Int. Ed. Engl. 59, 23094–23099 (2020).
- Gao, R. T. et al. Pt-induced defects curing on BiVO₄ photoanodes for near-threshold charge separation. Adv. Energy Mater. 11, 2102384 (2021).
- Gao, R. T., Liu, X., Zhang, X. & Wang, L. Steering electron transfer using interface engineering on front-illuminated robust BiVO₄ photoanodes. *Nano Energy* 89, 106360 (2021).
- Deng, J. et al. Improved water oxidation of Fe₂O₃/Fe₂TiO₅ photoanode by functionalizing with a hydrophilic organic hole storage overlayer. ACS Catal. 12, 7833–7842 (2022).

- Braiek, Z., Naceur, J. B., Jrad, F., Assaker, I. B. & Chtourou, R. Novel synthesis of graphene oxide/In₂S₃/TiO₂ NRs heterojunction photoanode for enhanced photoelectrochemical (PEC) performance. *Int. J. Hydrog. Energy* 47, 3655–3666 (2022).
- Chen, Z., Li, Y., Wang, L., Bu, Y. & Ao, J. P. Development of a bi-compound heterogeneous cocatalyst modified p-Si photocathode for boosting the photoelectrochemical water splitting performance. J. Mater. Chem. 9, 9157–9164 (2021).
- Zhang, M. et al. Acceptor-doping accelerated charge separation in Cu₂O photocathode for photoelectrochemical water splitting: theoretical and experimental studies. Angew. Chem. Int. Ed. 132, 18621–18625 (2020).
- 11. Yamaguchi, A., Sako, H. & Miyauchi, M. Synthesis of CaFe₂O₄ nanorod thin film using molten salt method and analysis of its photoelectrochemical properties. *Chem. Lett.* 49, 1462–1464 (2020).
- Yang, W. & Moon, J. Recent advances in earth-abundant photocathodes for photoelectrochemical water splitting. *Chemsuschem* 12, 1889–1899 (2019).
- Babu, M. H., Podder, J., Dev, B. C. & Sharmin, M. p to n-type transition with wide blue shift optical band gap of spray synthesized Cd doped CuO thin films for optoelectronic device applications. *Surf. Interfaces* 19, 100459 (2020).
- Masudy-Panah, S. et al. Rapid thermal annealing assisted stability and efficiency enhancement in a sputter deposited CuO photocathode. RSC Adv. 6, 29383-29390 (2016).
- Jeong, H., Ryu, H. & Bae, J. S. Improvement of CuO photostability with the help of a BiVO₄ capping layer by preventing selfreduction of CuO to Cu₂O. J. Ind. Eng. Chem. 104, 416–426 (2021).
- Yang, J. *et al.* Enhanced photoelectrochemical hydrogen evolution at p-type CuBi₂O₄ photocathode through hypoxic calcination. *Int. J. Hydrog. Energy* 43, 9549–9557 (2018).
- Berglund, S. P. et al. Comprehensive evaluation of CuBi₂O₄ as a photocathode material for photoelectrochemical water splitting. J. Mater. Chem. 28, 4231–4242 (2016).
- Cao, D. *et al.* p-Type CuBi₂O₄: an easily accessible photocathodic material for high-efficiency water splitting. *J. Mater. Chem. A.* 4, 8995–9001 (2016).
- Li, C. L., He, J. F., Xiao, Y. Q., Li, Y. B. & Delaunay, J. J. Earthabundant Cu-based metal oxide photocathodes for photoelectrochemical water splitting. *Energy Environ. Sci.* 13, 3269–3306 (2020).
- Ma, C. Y., Ma, D. K., Yu, W. Y., Chen, W. & Huang, S. M. Ag and N-doped graphene quantum dots co-modified CuBi₂O₄ submicron rod photocathodes with enhanced photoelectrochemical activity. *Appl. Surf. Sci.* 481, 661–668 (2019).
- Wang, Y. J., Wang, H. J., Woldu, A. R., Zhang, X. H. & He, T. Optimization of charge behavior in nanoporous CuBi₂O₄ photocathode for photoelectrochemical reduction of CO₂. Catal. Today 335, 388–394 (2019).
- 22. Kang, D., Hill, J. C., Park, Y. & Choi, K. S. Photoelectrochemical properties and photostabilities of high surface area CuBi₂O₄ and Ag doped CuBi₂O₄ photocathodes. *Chem. Mater.* **28**, 4331–4340 (2016).
- Li, S., Xu, W., Meng, L., Tian, W. & Li, L. Recent progress on semiconductor heterojunction-based photoanodes for photoelectrochemical water splitting. Small Sci. 2, 2100112 (2022).
- Pulipaka, S., Boni, N., Ummethala, G. & Meduri, P. CuO/CuBi₂O₄ heterojunction photocathode: high stability and current densities for solar water splitting. J. Catal. 387, 17–27 (2020).
- Li, Z. et al. Gd-doped CuBi₂O₄/CuO heterojunction film photocathodes for photoelectrochemical H₂O₂ production through oxygen reduction. Nano Res. 14, 3439–3445 (2021).
- Zhang, Q., Zhai, B., Lin, Z., Zhao, X. & Diao, P. CuO/CuBi₂O₄ bilayered heterojunction as an efficient photocathode for photoelectrochemical hydrogen evolution reaction. *Int. J. Hydrog. Energy* 46, 11607–11620 (2021).
- 27. Cai, F. *et al.* One step synthesis of tetragonal-CuBi₂O₄/amorphous-bifeo3 heterojunction with improved charge separation and enhanced photocatalytic properties. *Nanomatererials* **10**, 1514 (2020).
- Lam, N. H. et al. Fabrication and characterization of the broccoli-like structured CuO thin films synthesized by a facile hydrothermal method and its photoelectrochemical water splitting application. Met. 12, 484 (2022).
- Jiang, Z. et al. Preparation of CuBi₂O₄ photocathodes for overall water splitting under visible light irradiation. Mater. Sci. Semicond. Process 134, 105989 (2021).
- Begum, A., Hussain, A. & Rahman, A. Effect of deposition temperature on the structural and optical properties of chemically prepared nanocrystalline lead selenide thin films. *Beilstein J. Nanotechnol.* 3, 438–443 (2012).
- Momma, K. & Izumi, F. VESTA 3 for three-dimentional visualization of crystal, volumetric and morphology data. J. Appl. Cryst. 44, 1272–1276 (2011).
- Zhu, X. et al. Amorphous TiO₂-modified CuBi₂O4 Photocathode with enhanced photoelectrochemical hydrogen production activity. Chin. J. Catal. 39, 1704–1710 (2018).
- Abdulkarem, A. M. et al. CuBi₂O₄ single crystal nanorods prepared by hydrothermal method: Growth mechanism and optical properties. Mater. Res. Bull. 46(9), 1443–1450. https://doi.org/10.1016/j.materresbull.2011.05.005 (2011).
- Chen, Z., Dinh, H. N. & Miller, E. Photoelectrochemical Water Splitting: Standards, Experimental Methods, and Protocols (Springer, 2013).
- 35. Nogueira, A. C. *et al.* Improved visible light photoactivity of $\text{CuBi}_2\text{O}_4/\text{CuO}$ heterojunctions for photodegradation of methylene blue and metronidazole. *J. Phys. Chem. C* **123**, 25680–25690 (2019).
- Zhu, L. et al. Visible light-induced photoeletrochemical and antimicrobial properties of hierarchical CuBi₂O₄ by facile hydrothermal synthesis. ChemistrySelect 1, 1518–1524 (2016).
- Li, J., Griep, M., Choi, Y. & Chu, D. Photoelectrochemical overall water splitting with textured CuBi₂O₄ as a photocathode. *Chem. Commun.* 54, 3331–3334 (2018).
- Lee, S. A. et al. Electrodeposited heterogeneous nickel-based catalysts on silicon for efficient sunlight-assisted water splitting. Cell Rep. 1, 100219 (2020).
- Wei, S. *et al.* Rationally designed heterojunction on a CuBi₂O₄ photocathode for improved activity and stability during photoelectrochemical water reduction. *ChemElectroChem* 6, 3367–3374 (2019).
- 40. Gao, R. T. *et al.* Dynamic semiconductor-electrolyte interface for sustainable solar water splitting over 600 h under neutral conditions. *Sci. Adv.* **9**, 4589 (2023).
- Wang, F., Yang, H., Zhang, H. & Jiang, J. Growth process and enhanced photocatalytic performance of CuBi₂O₄ hierarchical microcuboids decorated with Au–Ag alloy nanoparticles. *J. Mater. Sci. Mater.* 29, 1304–1316 (2018).
- Li, Z. J. *et al.* Photoelectrochemically active and environmentally stable CsPbBr₃/TiO₂ core/shell nanocrystals. *Adv. Funct. Mater.* 28, 1704288 (2018).
- Gottesman, R. *et al.* Pure CuBi₂O₄ photoelectrodes with increased stability by rapid thermal processing of Bi₂O₃/CuO grown by pulsed laser deposition. *Adv. Funct. Mater.* **30**, 1910832 (2020).
- Nasori, N., Rubiyanto, A. & Endarko, E. Comparative study of p-type CuBi₂O₄ films and CuBi₂O₄ nanopillars photocathode for high performance photoelectrochemical water splitting. J. Phys. Conf. Ser. 1373, 012016 (2019).
- Le, N. *et al.* Direct growth of Bi₂S₃ nanorods onto the Bi₂MoO₆ nanoflakes: a promising heterostructure for efficient photoelectrochemical water-splitting application. *FlatChem.* 37, 100468 (2023).

Acknowledgements

This work was supported by Basic Science Research Program through the National Research Foundation of Korea (NRK) funded by the Ministry Education (Grant Number – NRF-2022R111A1A01071414).

Author contributions

N.H.L. wrote the original draft preparation, conceptualization, data interpretation; J.J.; conducted the data curation validation, resource; N.L. conducted the visualization, formal analysis; N.T.N.T. wrote, reviewed and edited; C.D.K. and K.-s.A. supervised the research; J.H.J. maganed the project administration, funding acquisition. All authors have read and agreed to the published version of the manuscript.

Competing interests

The authors declare no competing interests.

Additional information

Supplementary Information The online version contains supplementary material available at https://doi.org/ 10.1038/s41598-023-32804-0.

Correspondence and requests for materials should be addressed to N.T.N.T., C.-D.K. or J.H.J.

Reprints and permissions information is available at www.nature.com/reprints.

Publisher's note Springer Nature remains neutral with regard to jurisdictional claims in published maps and institutional affiliations.

Open Access This article is licensed under a Creative Commons Attribution 4.0 International License, which permits use, sharing, adaptation, distribution and reproduction in any medium or format, as long as you give appropriate credit to the original author(s) and the source, provide a link to the Creative Commons licence, and indicate if changes were made. The images or other third party material in this article are included in the article's Creative Commons licence, unless indicated otherwise in a credit line to the material. If material is not included in the article's Creative Commons licence and your intended use is not permitted by statutory regulation or exceeds the permitted use, you will need to obtain permission directly from the copyright holder. To view a copy of this licence, visit http://creativecommons.org/licenses/by/4.0/.

© The Author(s) 2023